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Impact of Current Profile on Transport and Stability in High Noninductive Fraction DIII-D Discharges<sup>1</sup> F. TURCO, ORAU, T.C. LUCE, J.R. FERRON, P.A. POLITZER, M.A. VAN ZEELAND, S.P. SMITH, A.M. GARO-FALO, A.D. TURNBULL, GA, C.T. HOLCOMB, LLNL, A.E. WHITE, MIT-PSFC, M. OKABAYASHI, PPPL, Y. IN, FAR-TECH, H. REIMERDES, Columbia U., D.P. BRENNAN, R. TAKAHASHI, U. Tulsa — Experiments addressing the issue of  $J_{BS}$ and  $J_{EC}$  alignment and the optimum q profile for stable noninductive operation show the  $J_{NI}$  and J profiles are best aligned at  $q_{min} \sim 1.5$ ,  $q_{95} \sim 6.8$ . The kinetic profiles vary systematically with  $q_{min}$  and  $q_{95}$ . Transport analysis shows that electrons dominate losses at low  $q_{min}$ , while at high  $q_{min}$  ions dominate. Drift wave stability analysis with the TGLF model shows trends in the linear growth rates that contradict these observations. Systematic scans of EC deposition indicate that a broad ECCD profile at  $\rho \sim 0.3 - 0.55$  yields a J profile that is more stable to the tearing modes that limit the duration of the discharges. Optimal alignment of  $J_{EC}$ for tearing stability coincides with the region where additional NI current is needed for  $f_{NI} = 1$ .

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